

United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.		
08/31/2000	Trung T. Doan	303.928US5	4284		
21186 7590 10/03/2006 SCHWEGMAN, LUNDBERG, WOESSNER & KLUTH, P.A.			EXAMINER MACARTHUR, SYLVIA		
	1	1763			
•		DATE MAILED: 10/03/2000	DATE MAILED: 10/03/2006		
	08/31/2000 590 10/03/2006 AN, LUNDBERG, WOE	08/31/2000 Trung T. Doan 590 10/03/2006 AN, LUNDBERG, WOESSNER & KLUTH, P.A. 3	08/31/2000 Trung T. Doan 303.928US5 590 10/03/2006 EXAM AN, LUNDBERG, WOESSNER & KLUTH, P.A. BIS, MN 55402 ART UNIT 1763		

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application	No.	Applicant(s)				
Office Action Summary		09/652,713	09/652,713 DO		OAN, TRUNG T.			
		Examiner		Art Unit				
		Sylvia R. Ma	cArthur	1763				
	of this communication app	pears on the c	over sheet with the c	orrespondence ad	dress			
Period for Reply				a) as Turst (a	0) 541/0			
- Failure to reply within the set or ext	R, FROM THE MAILING DA e under the provisions of 37 CFR 1.13 illing date of this communication. bove, the maximum statutory period w ended period for reply will, by statute, er than three months after the mailing	ATE OF THIS 36(a). In no event will apply and will e c, cause the applica	S COMMUNICATION, however, may a reply be time expire SIX (6) MONTHS from the tion to become ABANDONEI	l. ely filed the mailing date of this co O (35 U.S.C. § 133).				
Status								
1) Responsive to comm	nunication(s) filed on 14 Se	eptember 20	<u>26</u> .					
2a) ☐ This action is FINAL								
3) Since this application								
closed in accordance	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.							
Disposition of Claims								
4)⊠ Claim(s) <u>36-41</u> is/are	e pending in the application	n.						
4a) Of the above claim(s) is/are withdrawn from consideration.								
5) Claim(s) is/ar	5) Claim(s) is/are allowed.							
6)⊠ Claim(s) <u>36-41</u> is/are	e rejected.							
7) Claim(s) is/ar	e objected to.							
8) Claim(s) are	subject to restriction and/or	r election req	uirement.					
Application Papers								
9)☐ The specification is o	bjected to by the Examine	er.						
10)⊠ The drawing(s) filed o	•		ed or b)□ objected t	o by the Examine	r.			
Applicant may not requ	est that any objection to the	drawing(s) be	held in abeyance. See	37 CFR 1.85(a).				
Replacement drawing	sheet(s) including the correct	tion is required	if the drawing(s) is obj	ected to. See 37 CF	FR 1.121(d).			
11) ☐ The oath or declaration	on is objected to by the Ex	kaminer. Note	the attached Office	Action or form PT	O-152.			
Priority under 35 U.S.C. § 11	9							
12) Acknowledgment is n		priority unde	r 35 U.S.C. § 119(a)	-(d) or (f).				
a) ☐ All b) ☐ Some * 1. ☐ Certified copie	c) None or. es of the priority documents	s have been	received					
•	es of the priority documents			on No.				
——··	certified copies of the prior				Stage			
<u>.</u>	m the International Bureau	-			3			
• •	iled Office action for a list	•	* **	d.				
Attachmont/s					_			
Attachment(s) 1) Notice of References Cited (PT	O-892)	4) Interview Summary	(PTO-413)				
2) Notice of Draftsperson's Patent	Drawing Review (PTO-948)		Paper No(s)/Mail Date					
 Information Disclosure Stateme Paper No(s)/Mail Date <u>9/14/200</u> 			5) Notice of Informal Patent Application 6) Other:					

Art Unit: 1763

DETAILED ACTION

1. The RCE sent 9/14/2006 has been accepted.

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

3. Claims 36-39 and 41 are rejected under 35 U.S.C. 102(e) as being anticipated by Tzeng et al (US 5,756,155).

The prior art of Tzeng et al teaches a combination nozzle and a vacuum hood that is self cleaning.

Regarding claims 36, 37, and 41: The device comprises a dispenser (inclusive of elements 22 and path 11 and outlet 16) and splash controller (vaccum port inclusive of element 15, 18) see Figs. 2-5. Fig. 4 especially features two concentric nozzles and col.5 lines 5-16. The nozzle is configured to treat the periphery of the wafer according to col. 5 lines 50-65.

Regarding claim 38: The vacuum nozzle completely surrounds the dispenser according to Fig. 4.

Regarding claim 39: See Figs. 2-5.

Art Unit: 1763

Regarding the limitation in claims 36 and 41 that the splash controller generate a gas pressure around the edge that is lower than ambient gas pressure this limitation is inherently perform as a vacuum is provided.

4. Claims 36-39 and 41 are rejected under 35 U.S.C. 102(e) as being anticipated by Sukenari (JP 08-017708).

Using the English Translation of the patent, it is noted that the prior art of Sukenari teaches a dual nozzle to remove a film from the periphery of the wafer, see the abstract.

Regarding claims 36, 37, and 41: The device comprises a dispenser (including 14 and 16) and splash controller (including 17 and 15) see the picture on the English Abstract.

Note the nozzles are concentric. The nozzle is configured to treat the periphery of the wafer according to the abstract.

Regarding claim 38: The vacuum nozzle completely surrounds the dispenser according to the figure

Regarding claim 39: See the figure.

Regarding the limitation in claims 36 and 41 that the splash controller generate a gas pressure around the edge that is lower than ambient gas pressure this limitation is inherently perform as a vacuum is provided.

Claim Rejections - 35 USC § 103

- 5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary

Art Unit: 1763

skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

6. Claim 40 is rejected under 35 U.S.C. 103(a) as being unpatentable over Tzeng et al or Sukenari.

The teachings of Tzeng et al or Sukenari were discussed above.

Tzeng et al or Sukenari fails to teach a second nozzle to treat the underside of the wafer. However, the duplication of parts was held to have been obvious by In re Harza 274 F 2d 669, 124 USPQ 378 (CCPA 1960). Making the duplicate nozzles wherein one treats the top of the wafer and the other treats the bottom of the wafer integral is also an obvious matter of design according to In re Larson, 340 F.2d 965, 968, 144 USPQ 347, 349 (CCPA 1965) (A claim to fluid transporting vehicle was rejected as obvious over a prior art reference which differed from the prior art in claiming a brake drum integral with a clamping means, whereas the brake disc and clamp of the prior art comprise several parts rigidly secured together as a single unit. The court affirmed the rejection holding, among other reasons," that the use of a one piece construction instead of the structure disclosed in [the prior art] would be merely a matter of obvious engineering choice."). In this case, it would have been obvious for one of ordinary skill in the art at the time of the claimed invention to provide a nozzle as taught by Tzeng et al or Sukenari to treat both sides of the wafer and integral these nozzles to simplify the apparatus design all allow them to be controlled unitarily. Thus, it would have been obvious at the time of the claimed invention to provide the apparatus of Tzeng et al or Sukenari with a duplicate of the taught nozzle wherein both sides of the wafer are treated.

Response to Arguments

Art Unit: 1763

7. Applicant's arguments with respect to claims 36-41 have been considered but are moot in view of the new ground(s) of rejection.

The prior art of Tzeng et al or Sukenari both teach concentric nozzle to clean the edge bead of a wafer.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sylvia R. MacArthur whose telephone number is 571-272-1438. The examiner can normally be reached on M-F during the hours of 8:30 a.m. and 5 p.m.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Parviz Hassanzadeh can be reached on 571-272-1435. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Sylvia R MacArthur Patent Examiner Art Unit 1763